# Rapid Solidification of AI-7 wt.% Si Using The Twin-Roll Technique

#### Maftah H. Alkathafi and Awanikumar P. Patil

Abstract— The aim of this study is to understand the improvement in the properties of Al-7% Si with rapid solidification processing using the twin-roll technique. The process is based on two rolls rotating in opposite direction with 3900 revolution per minute (r.p.m.). The rapid solidification leads to a fine particle distribution of the second phase in the aluminium matrix. It is found in the metallographies test that the second phase undergoes coarsening on annealing and extent of coarsening increases with increasing annealing temperature (200, 300, 400 and 500°C). It is also found that the micro-hardness is increased with rapid solidification and decreased in subsequent annealing. The micro-hardness depends on the thickness of the ribbon where with lower thickness the micro-hardness increases because of the highest cooling rate. This is attributed to increasing the chilling effect on decreasing thickness of ribbon. X-ray diffraction was employed and it was found that the lattice parameter of rapidly solidified sample was more than the slowly cooled one. It is attributed to entrapment of silicon in the aluminium matrix owing to rapid solidification.

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Keywords: Rapid Solidification, Twin-Roll Technique, Annealing, Al-7% Si.

#### **1** INTRODUCTION

C ast Aluminium-Silicon alloys have been studied in detail due to their excellent combination of properties such as fluidity, low coefficient of thermal expansion and high wear resistance. The Al-Si phase diagram is a simple eutectic system type; two metals are completely soluble in the liquid state but silicon is only partly soluble in the FCC structure of Al, while the solid solubility of Al in Si is negligible. The phase diagram for Al-Si is shown in Figure 1. The melting point of aluminium and silicon are 660.37°C and 1414°C, respectively. The eutectic temperature is 577°C with eutectic composition of 12.6 wt.% Si and the maximum solubility of Si in Al is 1.65 wt.%. Hypoeutectic alloys form coarse dendrite grains of alpha-Al and large brittle flakes of Si. Such cast structure is brittle and exhibits poor ductility and also makes machining difficult. For this reason, Al-Si eutectic is modified with additives like Ce, Sr, No, Sb, CA, P, B, etc. to improve strength and ductility of the alloys [1],[2],[3]. A method called 'Strain Induced Melt Activation' (SIMA) is also used to obtain globular  $\alpha_{AI}$  grains [4].

As a result of this modification Al-Si alloys are finding a large number of applications in automobile industries [5]. In addition, rapid solidification of metals and alloys has become a field of extensive attention, since this method offers prospect of new or improved engineering materials with superior

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properties. All methods of rapid solidification produce structures which otherwise can not be obtained economically by other manufacturing techniques like casting, rolling or forging. In addition, the creation of certain shapes such as ribbons, wires, powder particles may be aspired to meet certain requirements. Rapid solidification of alloys leads to extension of solid solubility, decreasing grain size, and enhanced supersaturation of alloying elements [6]. The twin-roll technique is one of the techniques that are used for rapid solidification processes. The technique essentially consists of melting an alloy charge in a crucible and pouring the melt directly into a gap between a pair of rapidly counter-rotating rollers held together by special design. The resulting material emerges from the nip, the thickness of solidified material is a function of contact time (or residence time) with the roller surface, while the overall thickness of the solidified material is partially controlled by roll gap. The products from various rapid quenching techniques come under the general classification of powder, flake, foil and wire. These products exhibit unique microstructure which may be amorphous (metallic glasses), microcrystalline or other structures. The present work deals with modification of Al-Si alloy micro-structure without the addition of a modifier by employing a twin roll technique.

#### **2 EXPERIMENTAL PROCEDURE**

#### 2.1 Rapid Solidification Using The Twin - Roll technique

The equipment that has been used in the work to produce rapid solidified specimens by the twin-roll technique is shown in Figure 2. Double rolls are made of red copper and each has a diameter of 75mm and length 100mm. Copper is chosen because it has a very high thermal conductivity and thus will be able to produce a greater chilling effect without artificial cooling arrangement. The pure Al and Al-7% Si were melted in covered crucible, starting from virgin metals, in a furnace maintained at 750 °C and 950°C, respectively.

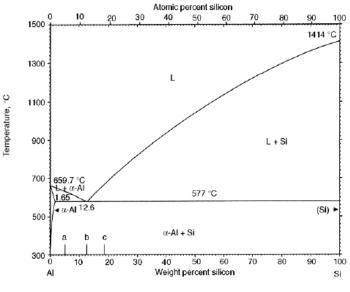


Fig. 1. Al-Si Phase Diagram [7]

The rolls were cleaned to remove any contamination from their smooth surface, and cooled by pieces of ice for a long time until the roll temperature was close to ice temperature. The speed of rolls was fixed at about 3900 r.p.m. and that is the maximum speed that could be obtained from the equipment. When the rolls reached to the maximum speed the molten material was poured into the gap of about 0.3mm between the rolls. The crucible was kept very close to the gap during pouring to minimize chances of air pick-up and oxidation. The mechanistic steps of rapid solidification are shown in Figure 3. In region-I the feed remains molten; solidification commences at the surface of cool rolls in the region-II and solidified material is being deformed in the region-III. The resultant specimens have different thicknesses less than 0.3 mm. On the other hand, samples of Al-7% Si and pure-Al were also obtained by casting and furnace cooling to obtain conventional cast structure as reference specimens.

#### 2.2 Annealing

After rapid solidification specimens of Al-7wt.% Si and pure-Al with varying thickness were annealed at different temperature, 200, 300, 400 and 500°C for one hour. In addition, one 0.2 mm thick rapid solidified specimen was annealed at 500°C for 20hrs. All samples that were exposed to annealing were covered with powdered flux to avoid surface oxidation.

## 2.3 Microhardness Test:

The microhardness of Al-7wt% Si alloy sample was measured using a Vickers hardness testing machine. The applied load was 25g for a dwell time of 20 seconds. The micro-hardness measurements were taken along two perpendicular axes on each side of the sample, and at least five readings were taken for each sample. The average of these readings is reported.

## 2.4 X-Ray Analysis

X-ray diffraction (XRD) technique was used to ascertain increased solid solubility of silicon in aluminium due to rapid solidification and also to find out if Al<sub>2</sub>O<sub>3</sub> and SiO<sub>2</sub> formed in the alloy during melting due to oxidation. XRD was carried out on diffractometer with a copper tube target and a nickel filter in to obtain Cu K $\alpha$  monochromatic radiation ( $\lambda_{le}$  = 1.542 A). The x-ray diffractometer was rotated at speed in 2º/min, while the chart speed was selected to be 2cm/min. Two samples of Al-7wt% Si with different cooling rates were subjected to XRD. One of the samples tested was produced by rapid solidification at a higher cooling rate and was 0.1mm thick. The XRD machine was operated at an applied voltage of 32 KV and tube current of 25 mA. The other sample tested was produced by the slower cooling rate (slow cooling) and was in the powder form. For this sample the XRD machine was operated at an applied voltage of 40 KV and tube current of 35mA.

#### 2.5 Metallography Test

The speciments for metallography were prepared by mounting specimens in a cold setting resine. The liquid hardens in a matter of hours to yield a strong, convenient handle for holding the specimen during the subsequent steps in surface preparation. The surface preparation involves wet polishing on a series of emery papers (600, 800 and 1200 grit) with water as a lubricant and final polishing was done by 1 micron alumina (Al<sub>2</sub>O<sub>3</sub>). The Al-7%Si alloy specimens did not need etching owing to the fact that the particles of silicon appeared bright under the microscope. The microstructure of the specimens was examined under the microscope with different magnification.

# 3 RESULTS AND DISCUSSION 3.1 X-Ray Analysis

The diffraction pattern analysis for the rapid solidified specimen and slow cooled specimen is illustrated in Table 1 and 2, respectively. The inter-atomic spacing (a) can be determined for all possible h, k, l planes by the following equation:

a= d-measured 
$$\sqrt{h^{\star} + k^{\star} + l^{\star}}$$
 (1)

The average value of the inter-atomic spacing (a) was estimated to be 4.049<sup>A</sup> for Al (alpha Al) in rapidly solidified Al-7wt%Si, as shown in Table 1. However, the average value of (a) was 4.0338<sup>A</sup> for Al (alpha Al) in slow cooled Al-7wt%Si as shown in Table 2. This increment in lattice parameter of Al (alpha Al) due to rapid solidification indicates that the more

solute is in the solution. This is attributed to insufficient time for the excess Si to diffuse out of the Al lattice and as a result the lattice is elongated. This also means that the rapid solidification caused an increase in the solid solubility of Si in Al (to produce an alpha Al solid solution). This also indicates that by rapid solidification supersaturated solid solutions can be formed. It also indicates that inter-atomic spacing for Si in rapidly solidified specimen is more (i.e. average value of 5.418) than that for Si in slow cooled specimen (i.e. average value of 5.406). This means that due to rapid solidification there was insufficient time for Al atoms to diffuse out of Si lattice.

Oxidation during melting of oxidizing elements like Al and Si is natural. Therefore, the oxide formed during melting is separated from the melt with the help of a fluxing agent. However, in order to make sure that the oxide is not entrapped in the rapidly solidified alloy, it's XRD spectrum was checked for the presence of their oxides (Al<sub>2</sub>O<sub>3</sub> and SiO<sub>2</sub>). The d-card for Al<sub>2</sub>O<sub>3</sub> shows a first peak at 5.45 **A**<sup>\*</sup>, second peak at 3.47 **A**<sup>\*</sup> and third peak at 3.72 **A**<sup>\*</sup>. The d-card for SiO<sub>2</sub> shows a first peak at 6.73 **A**<sup>\*</sup>, second peak = 4.74 **A**<sup>\*</sup> and third peak at 3.33 **A**<sup>\*</sup>. By comparison to the above values with d-measured in Table 1 and 2, it is clear that particles of these oxides are not entrapped in the alloys.

## 3.2 Metallography

Figure 4 presents the micro-structure of the slowly solidified alloy. In this figure large primary alpha-Al dendrites are seen in the coarse eutectic matrix. The microstructure is similar to those obtained by Chen et. al.[2] and Wang and Bian [3]. Large primary dendrites of alpha Al and coarse eutectic matrix form due to sufficient time available during slow cooling for the phases to precipitate and grow. Figure 5 shows the microstructure of rapidly solidified alloys. It is evident that the structure is very fine and single phased and unlike Figure. 4, there is no sign of alpha-Al dendrites or coarse eutectic matrix. This is because of the fact that due to rapid solidification there was a large number of nuclei and each nucleus did not get enough time to grow. As a result the microstructure is so fine that it could not be resolved at 500X magnification. However, there was still enough time for crystallization to occur as evidenced by XRD results. Therefore it can be said that the rapid solidification of the alloy, by the present twin roll method, produced very fine polycrystalline structure.

The ribbons were annealed at different temperatures (200, 300, 400 and 500°C) for one hour, and their microstructures are presented in Figures 6 to 9. It is evident that now some dark second phase is appearing, this may be Si. It is also observed that with increasing annealing temperature second phase (Si) particles become more and more coarse. In order to gain further information on the coarsening tendency of the silicon one sample was annealed at 500°C for 20hrs and its microstructure

is illustrated in Figure 10. The microstructure reveals that silicon particles are spherical and randomly distributed in the aluminum matrix. This is attributed to outward diffusion of Si from a supersaturated solid solution of Si in Al. This causes nucleation of separate Si phase and as the annealing continues more and more Si comes out of the supersaturated solid solution. This continuous supply of Si during annealing causes growth and coarsening of Si nuclei into spherical Si particles. This explanation also holds good for microstructure shown in Figures 6 to 9 and due to less time available the particles are fine and sizes of the particle increases with increasing the annealing temperature. This is because more energy is available at a higher temperature so it causes faster diffusion and faster growth of the second phase is particles.

#### 3.3 Micro-Hardness Measurements

Table 3 presents the result of the micro - hardness test for 0.2 mm rapidly solidified Al-Si alloy and pure Al and also for slow cooled cast alloy and pure Al. It is evident that microhardness of rapidly solidified alloy is many times higher as compared to slowly cooled alloy. This is attributed to the formation of supersaturated solid solution alpha-Al (of Si in Al) and formation of very fine eutectic (which has very small inter-dendritic spacing) in rapidly solidified alloy as compared to slowly cooled alloy. The super-saturation causes more lattice distortion, as evident from XRD results, and thereby increases hardness. It is also evident that the micro-hardness of the alloy is much more than that of pure Al. This is because; the formation of alpha-Al solid solution in the alloy causes more Al lattice distortion and associated solid solution strengthening. Figure 11 summarizes the effect of annealing temperature on the micro - hardness of the rapid solidified sample. It is seen that the micro-hardness decreases with increasing the annealing temperature. This behavior is attributed to decreasing distortion of Al lattice due to diffusion of Si out of solid solution. It is also found that the micro-hardness is affected by the ribbon thickness as well, as presented in Figure 12 and 13. It is evident that micro-hardness decreases with increasing ribbon thickness. This is attributed to increasing degree of quenching and associated grain refinement. That is because with decreasing roll gap less molten metal can get into the roll gap and therefore the less molten metal comes in contact with the cold copper rolls. This produces more severe quenching with decreasing roll gap and vice-a-versa. However, the micro-hardness of pure Al increase by 12 units i.e. from 44 to 56 HV as against a rise of 31 units in case of Al-7%Si alloy on deceasing thickness from 0.25 mm to 0.15 mm. In case of pure Al there is no contribution of solid solution strengthening but the severity of quenching would certainly cause grain refinement. This means that in the case of the Al-7% Si alloy, there is contribution of solid solution strengthening as well as grain refinement due to rapid solidification of Al-7% Si alloy.

# **4 CONCLUSIONS**

- The microhardness of pure-Al and Al-7 wt% Si alloy increases by rapid solidification.
- The growth morphology of Si is less spheroidal shape at rapid solidification but plate-like shape has observed at slow cooling .
- The microhardness of Al-7 wt% Si is greater than pure-Al with rapid solidification.
- The microhardness decreases as annealing temperature increases.
- By increasing annealing temperature coursing of Siparticles take place.
- The rapid solidification increases the solid solubility of Si in Al- matrix.
- The microhardness increases as ribbon thickness decreases.

# **5 ACKNOWLEDGMENTS**

The first author would like to thank the Ministry of Higher Education and Scientific Research-Libya and the Industry Researches Centre-Tripoli for extending all the help in this study.

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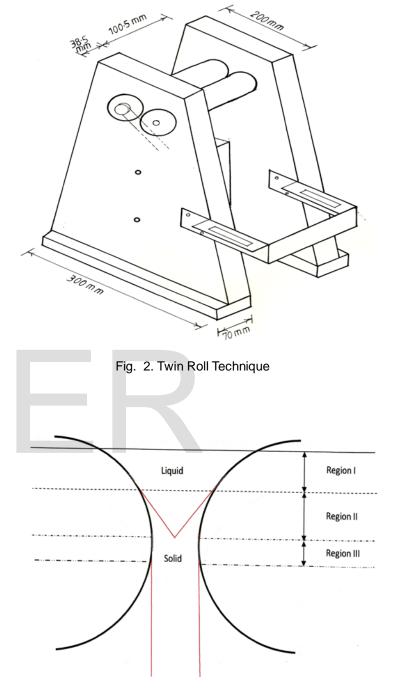


Fig. 3. The three steps of ribbon solidification during double roller quenching

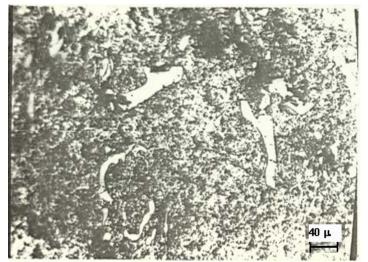


Fig. 4. Microstructure of slow cooling Al-7wt% Si, primary Al (light) and eutectic matrix, 500X

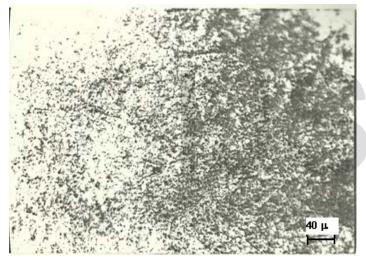


Fig. 5. Microstructure of rapidly solidified AI-7wt% Si, AI (light) matrix and fine Si (dark) particles,500X.

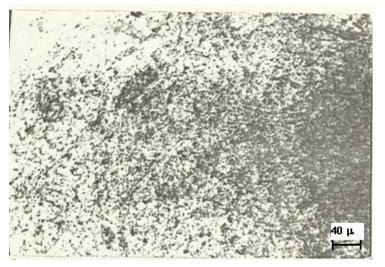


Fig. 7. Rapidly Solidified Al-7wt% Si, annealing at 300 r for 1hr, 500X.

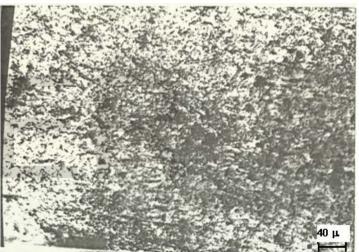
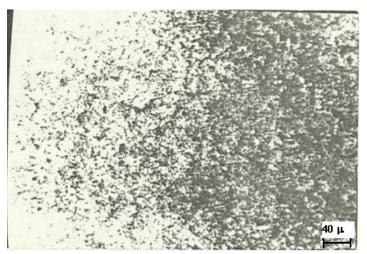


Fig. 8. Rapidly Solidified AI-7wt% Si, annealing at 400 °c for 1hr,500X.



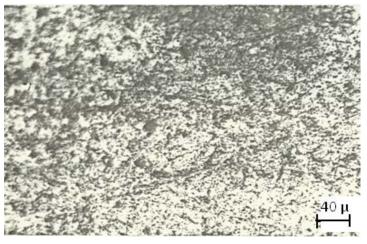


Fig. 9. Rapidly Solidified Al-7wt% Si, annealing at 500 r for 1hr, 500X.

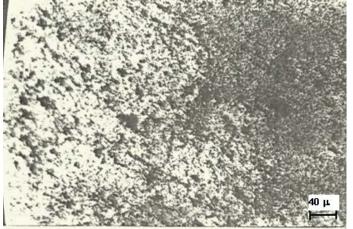


Fig. 10. Rapidly Solidified Al-7wt% Si and annealing at 500for 20hrs, 500X.

Table 1

Analysis of	Data	From	а	XRD	Spectrum	of	Rapidly	Solidified
Al-7 % Si								

20	θ	sin₿	d-measured	Ι
28.50	14.25	0.2461	3.1328	0.3
38.50	19.25	0.3297	2.3384	15.3
44.70	22.35	0.3803	2.0273	5.0
47.54	23.77	0.4031	1.9126	0.25
65.19	32.595	0.5387	1.4312	3.55
78.35	39.195	0.6317	1.2205	3.1
82.50	41.25	0.6593	1.1694	1.15
82.61	41.305	0.6601	1.1680	1.00

I %	d-card	hkl	Elem.	a
1.94	3.138	111	Si	5.426
100	2.338	111	Al	4.050
32.26	2.024	200	Al	4.0546
1.613	1.92	220	Si	5.4100
22.90	1.431	220	Al	4.048
20.0	1.221	311	Al	4.048
7.42	1.169	222	Al	4.051
6.452	1.169	222	Al	4.046

 Table 2

 Analysis of Data From a XRD Spectrum of Slowly Cooled Al-7

 % Si

20         9         sin@         d-measured         I           28.60         14.3         0.2469         3.1227         0.6           38.60         19.4         0.3321         2.3216         13.55           45.00         22.5         0.3826         2.0151         5.20           47.68         23.84         0.4041         1.9100         0.50           65.4         32.7         0.5402         1.4270         2.60           78.5         39.25         0.6327         1.2185         2.50	/0 01					
38.60         19.4         0.3321         2.3216         13.55           45.00         22.5         0.3826         2.0151         5.20           47.68         23.84         0.4041         1.9100         0.50           65.4         32.7         0.5402         1.4270         2.60	20	θ	sin₿	d-measured	Ι	
45.00         22.5         0.3826         2.0151         5.20           47.68         23.84         0.4041         1.9100         0.50           65.4         32.7         0.5402         1.4270         2.60	28.60	14.3	0.2469	3.1227	0.6	
47.68       23.84       0.4041       1.9100       0.50         65.4       32.7       0.5402       1.4270       2.60	38.60	19.4	0.3321	2.3216	13.55	
65.4         32.7         0.5402         1.4270         2.60	45.00	22.5	0.3826	2.0151	5.20	
	47.68	23.84	0.4041	1.9100	0.50	
78.5 39.25 0.6327 1.2185 2.50	65.4	32.7	0.5402	1.4270	2.60	
	78.5	39.25	0.6327	1.2185	2.50	

Ι%	d-card	hkl	Elem.	a
4.43	3.138	111	Si	5.410
100	2.338	111	Al	4.021
38.38	2.024	200	Al	4.030
3.69	1.92	220	Si	5.402
19.19	1.431	220	Al	4.036
18.45	1.221	311	Al	4.041

 Table 3

 Effect of Rapid Solidification on Micro-hardness of Test Alloys.

Specimen	Micro-hardness (HV)		
	Al-7% Si	pure-Al	
Rapid Cooling	176	50.20	
Slow Cooling	55.62	32.30	

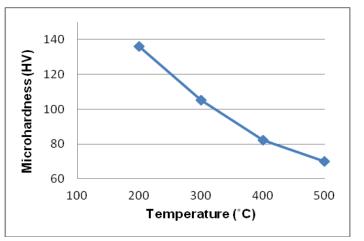


Fig. 11. The effect of annealing temperature on the micro - hardness of rapidly solidified AI-7% Si (annealing time:1hr)

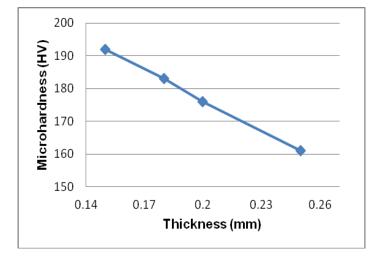


Fig. 12. Effect of ribbon thickness on micro-hardness of Al-7% Si

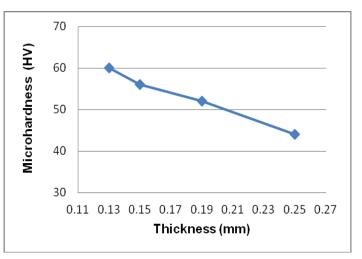


Fig. 13. Effect of ribbon thickness on micro-hardness of pure-Al

